Supplement of

Oxygenated organic molecules produced by low-NO_x photooxidation of aromatic

compounds and their contributions to secondary organic aerosol

Xi Cheng¹, Yong Jie Li², Yan Zheng¹, Keren Liao¹, Tong Zhu¹, Chunxiang Ye¹, Xinghua Qiu¹, Theodore K. Koenig¹, Yanli Ge¹, Qi Chen¹

¹State Key Joint Laboratory of Environmental Simulation and Pollution Control, BIC-ESAT and IJRC, College of Environmental Sciences and Engineering, Peking University, Beijing, China

²Department of Civil and Environmental Engineering, Department of Ocean Science and Technology, and Centre for Regional Oceans, Faculty of Science and Technology, University of Macau, Taipa, Macau, China

Correspondence: Qi Chen (qichenpku@pku.edu.cn) and Yong Jie Li (yongjieli@um.edu.mo)

Loss rate of OOMs

Losses of oxygenated organic molecules (OOMs) in an oxidation flow reactor (OFR) include the loss to the OFR walls (k_{wall} , s⁻¹), the loss to aerosol particles presented in the OFR (i.e., the condensation sink, CS, s⁻¹), and the loss to non-condensable products due to continuous reaction with OH (k_{OHloss} , s⁻¹) (Palm et al., 2016). According to the method described by Brune (2019) and Huang et al. (2018), k_{wall} of 0.0023-0.0028 s⁻¹ are used in our experiments. The CS was calculated using the data from scanning mobility particle sizer (SMPS), the average CS for the experiments herein is 0.02-0.07 s⁻¹. The average k_{OHloss} are then calculated as 0.02-0.04 s⁻¹ using the approach of Palm et al. (2016). More detailed descriptions could be found in our previous study (Cheng et al., 2021).

VBS parametrization

The volatility of gaseous OOMs was estimated using a volatility parameterization method (Mohr et al., 2019). The saturation concentrations (C^*) at 300 K for individual organic compounds are given by:

$$\log_{10}C^* = (n_0 - n_C) \times b_C - n_O \times b_O - 2(\frac{n_C \times n_O}{n_C + n_O}) \times b_{CO}$$
(S1)

)

where $n_0 = 25$, $b_C = 0.475$, $b_O = 0.2$, $b_{CO} = 0.9$, and n_C and n_O are the number of carbon and oxygen atoms in the compound, respectively (Donahue et al., 2011).

The saturation concentrations of compounds at ambient temperature were obtained by:

$$\log_{10}C^{*}(T) = \log_{10}C^{*}(300K) + \frac{\Delta H_{\text{vap}}}{\text{Rin}(10)} \left(\frac{1}{300} - \frac{1}{T}\right)$$
(S2)

where the evaporation enthalpy ΔH_{vap} can be linked to saturation concentration $\log_{10}C^*(300\text{K})$ via:

$$\Delta H_{\rm vap} \,[\rm kJ \, mol^{-1}] = -11 \log_{10} C^*(300 \rm K) + 129 \tag{S3}$$

The OOMs were then grouped into different bins within a volatility basis set (VBS) based on C^* (Donahue et al., 2006), and further classified as: ultralow volatility organic compound (ULVOC, $\log C^* \leq -9.5$); extremely low volatility organic compound (ELVOC, $-9.5 < \log C^* \leq -4.5$); low volatility organic compound (LVOC, $-4.5 < \log C^* \leq -0.5$); semi-volatile organic compound (SVOC, $-0.5 < \log C^* \leq 2.5$); intermediate volatility organic compound (IVOC, $2.5 < \log C^* \leq 6.5$) (Shrivastava et al., 2017; Bianchi et al., 2019; Schervish and Donahue, 2020).

Aerosol growth model

To evaluate the contribution of OOMs to secondary organic aerosols (SOA) through condensation, we used the aerosol growth model to calculate the net condensation flux of the observed OOMs (Tröstl et al., 2016), as follows:

$$\phi_{\rm p} = N_{\rm p} \times \sigma_{\rm p} \times s_{\rm p} \times F_{\rm p} \tag{S4}$$

Combining the first three terms, then the modified equation is:

$$\phi_{\rm p} = N_{\rm p} \pi D_{\rm p}^2 \times \frac{(D_{\rm p} + D_i)^2}{D_{\rm p}^2} \frac{v_{\rm i}}{4} \alpha_i \beta_i \times F_{\rm p}$$
(S5)

with N_p being the particle number concentration, D_p the particle diameter, D_i the vapour diameter, v_i the center of mass velocity for particle and vapor, α_i the accommodation coefficient, β_i the correction factor for the transition regime. F_p is the driving force of condensation, $F_p = C^v - X_p Y_p K_p C^*$, where C^v is the vapour (OOMs) concentration, C^* is the saturation concentration, X_p is the mass fraction of OOMs of each VBS bin in the condensed phase, and Y_p is the mass-based activity coefficient in the condensed phase (assuming $Y_p = 1$ as in ideal organic solution). The Kelvin term, $K_p = \exp(\frac{4\sigma M}{RT\rho D_p})$, which is related to the surface tension σ , molar weight M, and density ρ .

When the organic vapours in the gas and condensed phases reach equilibrium (F_p is zero), equilibrium partitioning theory is used to describe the condensation and evaporation of the organics onto or from particle surface (Pankow, 1994). The fraction of species *i* in the condensed phase is defined as:

$$f_i = \frac{1}{1 + C^*/C_{\text{OA}}} \tag{S6}$$

where C_{OA} is the concentration of organic aerosol in the condensed phase.

S2. General mechanism of OH-initiated chemistry of aromatic VOCs

The OH-initiated chemistry of aromatic volatile organic compounds (VOCs) mainly proceeds via addition to the aromatic ring to generate OH-aromatic adducts. If there are alkyl substitutions on the aromatic rings, reactions can also proceed via H-atom abstraction for normally $\leq 10\%$ probability (Jenkin et al., 2003). The alkyl radicals (R) formed either way react with O₂ and form a variety of RO₂ radicals, which undergo the following reaction channels under low-NO_x conditions: (1) bimolecular reaction route (reacting with HO₂ or RO₂ radicals) to form termination products or alkoxy radicals (RO), (2) phenolic route through HO₂ elimination, and (3) bicyclic intermediate route through cyclization (Jenkin et al., 2003; Nishino et al., 2012). The new alkyl (R) radical from the important pathway (3) can be converted to a new RO₂ radical by incorporating an O₂ molecule, forming a host of monomeric and dimeric OOMs via reactions R-S1 to R-S7 (Cheng et al., 2021; Garmash et al., 2020). Among these reactions, R-S1 is the autoxidation pathway that incorporates more and more oxygen atoms into the products while forming peroxide groups (-OOH) by internal H-shift; R-S2, R-S3, and R-S5 are termination reactions that lead to various monomeric products with different functional groups; R-S4 and R-S6 are the RO pathway between reactions of RO₂ and HO₂ or RO₂, and subsequent isomerization of RO might result in a new RO₂; R-S7 is the accretion reaction that leads to dimer formation.

Autoxidation pathway:

$$RO_2 \rightarrow \bullet QOOH; \bullet QOOH + O_2 \rightarrow R(OOH)O_2$$
 (R-S1)

General RO₂ pathways:

$$RO_2 + HO_2 \rightarrow ROOH + O_2$$
 (hydroperoxide channel) (R-S2)

$$RO_2 + HO_2 \rightarrow ROH + O_3 \text{ (hydroxyl channel)}$$
 (R-S3)

$$RO_2 + HO_2 \rightarrow RO + OH + O_2$$
 (alkoxy radical channel) (R-S4)

$$RO_2 + R'O_2 \rightarrow ROH + R'HC = O + O_2 (hydroxyl/carbonyl channel)$$
(R-S5)

$$RO_2 + R'O_2 \rightarrow RO + R'O + O_2$$
 (alkoxy radical channel) (R-S6)

$$RO_2 + R'O_2 \rightarrow ROOR' + O_2$$
 (dimer channel) (R-S7)



Figure S1. Time series of experimental conditions (irradiance in the OFR) and the example dimeric products from toluene and naphthalene oxidation. The grey shaded area represents "background" periods without VOC injection.



Figure S2. Concentrations of C_x products formed from the oxidation of (a) benzene, (b) toluene, (c) m-xylene, (d) 1,3,5-trimethylbenzene, (e) naphthalene and (f) 1-methylnaphthalene at different OH exposure. C_x products consist of open-shell and closed-shell monomers.



Figure S3. Concentrations of C_xH_{y+4} - and C_xH_{y+6} -series monomeric products formed from the oxidation of (a) naphthalene and (b) 1-methylnaphthalene at different OH exposure.



Figure S4. Concentrations of C_{2x} products formed from the oxidation of (a) benzene, (b) toluene, (c) m-xylene, (d) 1,3,5-trimethylbenzene, (e) naphthalene and (f) 1-methylnaphthalene at different OH exposure.



Figure S5. H:C and O:C ratios of gaseous OOMs formed from photooxidation of benzene, toluene, m-xylene, 1,3,5-trimethylbenzene, naphthalene and 1-methylnaphthalene at different OH exposure.



Figure S6. Concentration fractions of gaseous OOMs formed from the oxidation of **(a)** benzene, **(b)** toluene and **(c)** naphthalene at different OH exposure. OOMs are classified as five volatility classes: ULVOC, ELVOC, LVOC, SVOC, and IVOC.

Table S1. Parts of the peak list for benzene (C_6H_6) oxidation products shown in Fig. 1a.

Category	Formula	m/z (Th)	Fraction of fitted signals
	C ₃ H ₄ O ₅	181.99	9.2%
	$C_4H_4O_5$	193.99	14.3%
	$C_4H_6O_5$	196.01	2.1%
C ₂₋₅ monomeric products	$C_5H_4O_5$	205.99	6.6%
	$C_5H_6O_5$	208.01	1.5%
	$C_4H_4O_6$	209.99	2.6%
	$C_5H_4O_6$	221.99	7.8%
	$C_6H_6O_5$	220.01	3.0%
	C6H7O5	221.02	0.1%
	$C_6H_8O_5$	222.03	0.4%
	$C_6H_{10}O_5$	224.04	0.8%
	$C_6H_5O_6$	235.00	0.6%
	$C_6H_6O_6$	236.00	3.1%
	$C_6H_7O_6$	237.01	0.2%
	$C_6H_8O_6$	238.02	1.8%
	$C_6H_{10}O_6$	240.04	0.2%
	$C_6H_5O_7$	250.99	1.0%
	$C_6H_6O_7$	252.00	2.9%
	$C_6H_7O_7$	253.01	
	$C_6H_8O_7$	254.02	2.4%
	$C_{6}H_{9}O_{7}$	255.02	0.1%
	$C_{6H_{10}O_7}$	230.03	0.3%
C ₆ monomeric products	$C_{6}H_{5}O_{8}$	200.99	0.3%
	$C_6 H_6 O_8$	207.99	1.370
	$C_{6}H_{2}O_{8}$	209.00	1.0%
	$C_{6}H_{8}O_{8}$	270.01	0.1%
	$C_{6}H_{10}O_{8}$	271.02	0.170
	$C_{0}H_{10}O_{0}$	272.03	0.3%
	$C_{0}H_{2}O_{0}$	282.90	0.6%
	C ₆ H ₇ O ₉	285.00	0.9%
	C ₆ H ₈ O ₉	286.01	1.1%
	CeHaOa	287.01	0.3%
	$C_6H_{10}O_9$	288.02	0.4%
	C6H5O10	298.98	0.1%
	$C_6H_6O_{10}$	299.98	0.3%
	$C_{6}H_{7}O_{10}$	300.99	0.6%
	$C_{6}H_{8}O_{10}$	302.00	0.5%
	$C_{6}H_{10}O_{10}$	304.02	0.2%
	C ₁₁ H ₁₄ O ₉	352.05	0.04%
C ₁₀₋₁₁ dimeric products	$C_{10}H_{10}O_{12}$	384.01	0.1%
-	$C_{10}H_{12}O_{12}$	386.02	0.04%
	$C_{12}H_{14}O_8$	348.06	0.05%
	$C_{12}H_{14}O_9$	364.05	0.07%
	$C_{12}H_{10}O_{10}$	376.02	0.13%
	$C_{12}H_{12}O_{10}$	378.03	0.13%
	$C_{12}H_{14}O_{10}$	380.05	0.13%
	$C_{12}H_{16}O_{10}$	382.06	0.06%
	$C_{12}H_{10}O_{11}$	392.01	0.05%
	$C_{12}H_{12}O_{11}$	394.03	0.11%
C ₁₂ dimeric products	$C_{12}H_{14}O_{11}$	396.04	0.16%
	$C_{12}H_{16}O_{11}$	398.06	0.10%
	$C_{12}H_{10}O_{12}$	408.01	0.15%
	$C_{12}H_{12}O_{12}$	410.02	0.14%
	$C_{12}H_{14}O_{12}$	412.04	0.15%
	$C_{12}H_{16}O_{12}$	414.05	0.09%
	$C_{12}H_{10}O_{13}$	424.00	0.05%
	$C_{12}H_{12}O_{13}$	420.02	U.1 / %0
	$C_{12}H_{14}U_{13}$	428.03	0.15%
	$U_{12}H_{16}U_{13}$	430.05	0.09%

$C_{12}H_{10}O_{14}$	440.00	0.06%
$C_{12}H_{12}O_{14}$	442.01	0.06%
$C_{12}H_{14}O_{14}$	444.03	0.1%
C12H16O14	446.04	0.05%

Table S2. Parts of the peak list for toluene (C_7H_8) oxidation products shown in Fig. 1b.

Cotogomy	Formula	m/π (Th)	Erection of total fitted signals
Category		<u>m/z (11)</u>	
		181.99	2.4%
		193.99	5.9%
C ₂₋₆ monomeric products	$C_4H_6O_5$	196.01	9.5%
1	$C_5H_4O_5$	205.99	3.5%
	$C_5H_6O_5$	208.01	5.7%
	C5H4O6	221.99	7.2%
	$C_7H_8O_5$	234.03	1.3%
	$C_7H_9O_5$	235.03	0.1%
	$C_7H_{10}O_5$	236.04	0.6%
	$C_7H_7O_6$	249.01	0.2%
	$C_7H_8O_6$	250.02	3.8%
	$C_7H_9O_6$	251.03	0.2%
	$C_7H_{10}O_6$	252.04	2.1%
	$C_7H_{12}O_6$	254.05	0.1%
	C7H7O7	265.01	0.2%
	$C_7H_8O_7$	266.02	2.6%
	$C_7H_9O_7$	267.02	0.5%
	$C_7H_{10}O_7$	268.03	3.0%
	$C_7H_{11}O_7$	269.04	0.1%
	$C_7H_{12}O_7$	270.05	0.7%
C7 monomeric products	$C_7H_7O_8$	281.00	0.2%
	$C_7H_8O_8$	282.01	1.6%
	$C_7H_9O_8$	283.02	0.1%
	$C_{7}H_{10}O_{8}$	284.03	2.0%
	$C_7H_{11}O_8$	285.03	0.2%
	$C_7H_{12}O_8$	286.04	1.0%
	$C_7H_8O_9$	298.01	0.4%
	$C_7H_9O_9$	299.01	1.0%
	$C_7H_{10}O_9$	300.02	1.3%
	$C_7H_{11}O_9$	301.03	0.2%
	$C_7H_{12}O_9$	302.04	0.4%
	$C_{7}H_{8}O_{10}$	314.00	0.3%
	$C_{7}H_{9}O_{10}$	315.01	0.4%
	$C_7H_{10}O_{10}$	316.02	0.4%
	$C_7H_{12}O_{10}$	318.03	0.2%
	$C_{10}H_{10}O_9$	336.02	0.1%
C dimensio mas dusta	$C_{12}H_{10}O_8$	344.03	0.03%
C ₁₀₋₁₃ differic products	$C_{13}H_{12}O_9$	374.04	0.02%
	$C_{13}H_{14}O_{10}$	392.05	0.03%
	C ₁₄ H ₁₈ O ₈	376.09	0.03%
	$C_{14}H_{16}O_{9}$	390.07	0.04%
	$C_{14}H_{18}O_{9}$	392.08	0.03%
	$C_{14}H_{20}O_{9}$	394.10	0.01%
	$C_{14}H_{16}O_{10}$	406.06	0.06%
	$C_{14}H_{18}O_{10}$	408.08	0.1%
	$C_{14}H_{20}O_{10}$	410.09	0.04%
	$C_{14}H_{16}O_{11}$	422.06	0.08%
	$C_{14}H_{18}O_{11}$	424.07	0.08%
C ₁₄ dimeric products	$C_{14}H_{20}O_{11}$	426.09	0.11%
ł	$C_{14}H_{16}O_{12}$	438.05	0.07%
	$C_{14}H_{18}O_{12}$	440.07	0.13%
	$C_{14}H_{20}O_{12}$	442.08	0.07%
	$C_{14}H_{16}O_{13}$	454.05	0.07%
	$C_{14}H_{18}O_{13}$	456.06	0.1%
	$C_{14}H_{20}O_{13}$	458.08	0.08%
	$C_{14}H_{16}O_{14}$	470.04	0.05%
	$C_{14}H_{18}O_{14}$	472.06	0.07%
	$C_{14}H_{20}O_{14}$	474.07	0.05%

Table S3. Parts of the peak list for m-xylene (C_8H_{10}) oxidation products shown in Fig. 1c.

		((m)	
Category	Formula	m/z (Th)	Fraction of total fitted signals
	$C_3H_4O_5$	181.99	0.4%
	$C_4H_4O_5$	193.99	0.7%
	C5H4O5	205.99	0.2%
~	C5H6O5	208.01	1.5%
C ₂₋₇ monomeric products	CaHaOa	209.99	0.3%
	C ₅ H ₂ O ₅	210.03	0.1%
	C-H-O	212.00	0.2%
	$C_4 \Pi_6 O_6$	212.00	2 59/
	C5H6O6	224.00	2.370
	$C_8H_{10}O_5$	248.04	0.06%
	$C_{8}H_{11}O_{5}$	249.05	0.05%
	$C_8H_{12}O_5$	250.06	0.2%
	$C_8H_8O_6$	262.02	0.5%
	$C_8H_{10}O_6$	264.04	2.3%
	$C_8H_{11}O_6$	265.04	0.7%
	$C_8H_{12}O_6$	266.05	1.5%
	$C_8H_{13}O_6$	267.06	0.1%
	$C_8H_{14}O_6$	268.07	0.2%
	$C_{8}H_{8}O_{7}$	278.02	1.6%
	$C_{\rm e}H_{\rm e}O_7$	279.02	0.1%
	$C_{0}H_{10}O_{7}$	280.03	8.6%
		280.03	
	$C_8H_{11}O_7$	281.04	0.9%
	$C_8H_{12}O_7$	282.05	
	$C_8H_{13}O_7$	283.05	0.4%
	$C_8H_{14}O_7$	284.06	1.8%
C. monomeric products	$C_8H_8O_8$	294.01	0.6%
C8 monomene products	$C_8H_9O_8$	295.02	0.1%
	$C_8H_{10}O_8$	296.03	6.4%
	$C_8H_{11}O_8$	297.03	0.9%
	$C_{8}H_{12}O_{8}$	298.04	4.6%
	$C_8H_{13}O_8$	299.05	0.9%
	$C_{\rm e}H_{\rm 14}O_{\rm e}$	300.06	3.5%
	$C_{8}H_{14}O_{8}$	312.02	2.6%
	C_{11009}	212.02	1.09/
	$C_{8}\Pi_{11}O_{9}$	214.04	
	$C_8H_{12}O_9$	314.04	
	$C_8H_{13}O_9$	315.04	0.6%
	$C_8H_{14}O_9$	316.05	2.3%
	$C_8H_9O_{10}$	327.01	0.1%
	$C_8H_{10}O_{10}$	328.02	0.5%
	$C_8H_{11}O_{10}$	329.02	0.1%
	$C_8H_{12}O_{10}$	330.03	1.0%
	$C_8H_{13}O_{10}$	331.04	0.5%
	$C_8H_{14}O_{10}$	332.05	0.6%
	C14H8O5	318.03	0.14%
	$C_{13}H_{10}O_6$	324.04	0.11%
	$C_{11}H_{14}O_{8}$	336.06	0.07%
C ₁₀₋₁₅ dimeric products		338.05	0.16%
	$C_{1411_{12}}C_6$	256.02	0.1070
		330.03	0.189/
	$C_{14}H_{20}O_{10}$	410.09	0.18%
	$C_{16}H_{18}O_7$	384.09	0.11%
	$C_{16}H_{18}O_8$	400.09	0.1%
	$C_{16}H_{18}O_9$	416.08	0.08%
	$C_{16}H_{20}O_9$	418.10	0.06%
	$C_{16}H_{22}O_9$	420.11	0.11%
C dimonis	$C_{16}H_{18}O_{10}$	432.08	0.08%
U ₁₆ aimeric products	$C_{16}H_{20}O_{10}$	434.09	0.14%
	$C_{16}H_{22}O_{10}$	436.11	0.3%
	$C_{16}H_{24}O_{10}$	438.13	0.28%
	$C_{16}H_{20}O_{11}$	450.09	0.26%
	$C_{12}H_{22}O_{11}$	452 10	0.37%
	$C_{10}H_{22}O_{11}$	454 12	0.48%
	0161124011	TJT.12	0.01.0

$C_{16}H_{20}O_{12}$	466.08	0.33%	
$C_{16}H_{22}O_{12}$	468.10	0.54%	
$C_{16}H_{24}O_{12}$	470.12	0.47%	
$C_{16}H_{20}O_{13}$	482.08	0.3%	
$C_{16}H_{22}O_{13}$	484.09	0.46%	
$C_{16}H_{24}O_{13}$	486.11	0.47%	
$C_{16}H_{20}O_{14}$	498.07	0.19%	
$C_{16}H_{22}O_{14}$	500.09	0.32%	
$C_{16}H_{24}O_{14}$	502.10	0.27%	

Table S4. Parts of the peak list for 1,3,5-trimethylbenzene (C₉H₁₂) oxidation products shown in Fig. 1d.

Category	Formula	m/z (Th)	Fraction of total fitted signals
Cutegory	C ₃ H ₄ O ₅	181.99	0.2%
	C4H4O5	193.99	0.7%
	$C_5H_4O_5$	205.99	0.1%
	C5H4O5	208.01	0.6%
	$C_4H_4O_6$	209.99	0.3%
	C5H2O5	210.03	0.1%
	$C_4H_6O_6$	212.00	0.5%
	$C_{4}H_{6}O_{5}$	212.00	0.3%
C ₂ « monomeric products	C5H4O6	221.99	0.5%
C2-6 monomente products	C5H4O6	224.00	0.8%
	C6H6O6	236.00	0.9%
	CeHeOe	238.02	0.9%
	$C_7H_{10}O_6$	252.04	0.8%
	$C_8H_{10}O_6$	264.04	1.5%
	$C_7H_8O_7$	266.02	0.7%
	$C_{8}H_{10}O_{7}$	280.02	3 1%
	$C_8H_{10}O_7$	282.05	1.8%
	CoH12O7	262.05	0.2%
	$C_0H_{12}O_5$	263.06	0.1%
	$C_0H_{13}O_5$	203.00	2 7%
	$C_{9}H_{12}O_{6}$	270.05	1.4%
	$C_{9}H_{14}O_{6}$	280.07	0.2%
	$C_{9}H_{16}O_{7}$	202.08	0.2/0
	$C_{9}H_{10}O_{7}$	292.05	1 A%
	$C_9H_{12}O_7$	294.03	0.13%
	$C_9\Pi_{13}O_7$	295.05	17 5%
	$C_9 H_1 4 O_7$	290.00	1 60/2
	C_9H_1SO7	297.07	3 40/2
	$C_9\Pi_{16}O_7$	298.08	0.5%
	$C_9II_{10}O_8$	310.04	6.0%
	$C_9\Pi_12O_8$	310.04	0.070
C. monomoria producto	$C_{9}H_{13}O_{8}$	311.05	0.570
C9 monomene products	С9П14О8	312.00	4.570
	$C_9\Pi_{15}O_8$	313.07	2 70/2
	$C_9\Pi_{16}O_8$	314.07	0.69/
	$C_9\Pi_{10}O_9$	324.02	0.070
	$C_9\Pi_12O_9$	320.04	2.570
		327.04	0.470
	С9П14О9	328.03	4.170
	$C_9\Pi_{15}O_9$	329.00	2.80/
	CoH color	330.07	2.070
	$C_9\Pi_{10}O_{10}$	340.02	0.170
	$C_9II_{12}O_{10}$	342.03	0.9%
	$C_{9}II_{13}O_{10}$	343.04	1 40/2
	$C_9II_14O_{10}$	344.03	0.5%
	$C_9H_1SO_{10}$	345.05	0.370
	С9П16О10	240.00	
	$C_{11}H_{18}O_8$	340.09	0.120/
C dimensional desta	$C_{12}H_{18}O_8$	352.09	0.15%
C ₁₀₋₁₇ dimeric products	$C_{11}H_{16}O_9$	354.07	0.05%
	$C_{14}H_{14}O_7$	356.06	0.05%
	$C_{12}H_{10}O_{12}$	408.01	0.12%
	$C_{18}H_{24}O_{10}$	462.13	0.09%
	$C_{18}H_{26}O_{10}$	464.14	0.19%
	$C_{18}H_{28}O_{10}$	466.16	0.08%
	$C_{18}H_{24}O_{11}$	478.12	0.11%
C ₁₈ dimeric products	$C_{18}H_{26}O_{11}$	480.14	0.13%
	$C_{18}H_{28}O_{11}$	482.15	0.16%
	$C_{18}H_{24}O_{12}$	494.12	0.23%
	$C_{18}H_{26}O_{12}$	496.13	0.37%
	$C_{18}H_{28}O_{12}$	498.15	0.22%

C ₁₈ H ₂₄ O ₁₃	510.11	0.1%	
$C_{18}H_{26}O_{13}$	512.13	0.23%	
$C_{18}H_{28}O_{13}$	514.14	0.18%	
$C_{18}H_{24}O_{14}$	526.10	0.12%	
$C_{18}H_{26}O_{14}$	528.12	0.18%	
 $C_{18}H_{28}O_{14}$	530.14	0.17%	

Table S5. Parts of the peak list for naphthalene $(C_{10}H_8)$ oxidation products shown in Fig. 1e.

Category	Formula	m/z (Th)	Fraction of total fitted signals
	C3H4O5	181.99	8.9%
	C ₄ H ₄ O ₅	193 99	9.3%
	$C_4H_4O_5$	196.01	1 7%
	$C_{4}H_{6}O_{5}$	205.00	2 70/2
	C3H4O5	205.55	1.00/
C monomorio produoto	$C_5\Pi_6O_5$	200.01	2 20/
C ₂₋₉ monomene products	$C_4\Pi_4O_6$	209.99	2.570
	$C_6\Pi_6O_5$	220.01	1.0%
	$C_5\Pi_4O_6$	221.99	2.5%
	$C_5H_8O_6$	226.02	5.0% 0.6%
	$C_7H_6O_6$	248.00	
	$C_9H_8O_7$	290.02	2.1%
	$C_{10}H_6O_5$	268.01	
	$C_{10}H_7O_5$	269.02	0.2%
	$C_{10}H_8O_5$	270.03	2.8%
	$C_{10}H_9O_5$	271.03	0.4%
	$C_{10}H_{10}O_5$	272.04	0.5%
	$C_{10}H_{11}O_5$	273.05	0.1%
	$C_{10}H_{12}O_5$	274.06	0.2%
	$C_{10}H_{13}O_5$	275.06	0.1%
	$C_{10}H_6O_6$	284.00	0.5%
	$C_{10}H_7O_6$	285.01	0.1%
	$C_{10}H_8O_6$	286.02	2.9%
	$C_{10}H_9O_6$	287.03	0.3%
	$C_{10}H_{10}O_6$	288.04	0.9%
	$C_{10}H_{11}O_6$	289.04	0.5%
	$C_{10}H_{12}O_6$	290.05	0.3%
	$C_{10}H_{13}O_6$	291.06	0.2%
	$C_{10}H_{14}O_6$	292.07	0.1%
	$C_{10}H_6O_7$	300.00	0.1%
	$C_{10}H_7O_7$	301.01	0.3%
	$C_{10}H_8O_7$	302.02	1.8%
	$C_{10}H_9O_7$	303.02	1.0%
	$C_{10}H_{10}O_7$	304.03	1.0%
	$C_{10}H_{11}O_7$	305.04	0.3%
	$C_{10}H_{12}O_7$	306.05	0.2%
C., monomoria producto	$C_{10}H_{13}O_7$	307.05	0.1%
C ₁₀ monomene products	$C_{10}H_{14}O_7$	308.06	0.1%
	$C_{10}H_6O_8$	315.99	0.1%
	$C_{10}H_7O_8$	317.00	0.3%
	$C_{10}H_8O_8$	318.01	0.5%
	$C_{10}H_9O_8$	319.02	1.1%
	$C_{10}H_{10}O_8$	320.03	1.0%
	$C_{10}H_{11}O_8$	321.03	0.3%
	$C_{10}H_{12}O_8$	322.04	0.3%
	$C_{10}H_{13}O_8$	323.05	0.1%
	$C_{10}H_{14}O_{8}$	324.06	0.1%
	$C_{10}H_6O_9$	331.99	0.1%
	$C_{10}H_7O_9$	333.00	0.1%
	$C_{10}H_8O_9$	334.01	0.4%
	$C_{10}H_9O_9$	335.01	0.3%
	$C_{10}H_{10}O_{9}$	336.02	0.6%
	$C_{10}H_{11}O_{9}$	337.03	0.3%
	$C_{10}H_{12}O_{9}$	338.04	0.5%
	$C_{10}H_{12}O_{0}$	339.04	0.1%
	$C_{10}H_{14}O_{0}$	340.05	0.1%
	$C_{10}H_7O_{10}$	348 99	0.4%
	$C_{10}H_{\circ}O_{10}$	350.00	0.2%
	$C_{10}H_{0}O_{10}$	351.01	0.5%
	$C_{10}H_{10}O_{10}$	352.02	0.7%
	$C_{10}H_{11}O_{10}$	353.02	0.170
	$C_{10}H_{12}O_{10}$	25/ 02	0.5%
	C101112O10	334.03	0.070

	C ₁₀ H ₇ O ₁₁	364.99	0.2%	
	$C_{10}H_8O_{11}$	366.00	0.2%	
	C ₁₀ H ₉ O ₁₁	367.00	0.2%	
	C10H10O11	368.01	0.4%	
	C ₁₀ H ₁₁ O ₁₁	369.02	0.2%	
	$C_{10}H_{12}O_{11}$	370.03	0.6%	
	C ₁₀ H ₁₃ O ₁₁	371.03	0.2%	
	$C_{10}H_{14}O_{11}$	372.04	0.3%	
	C10H7O12	380.98	0.1%	
	C10H8O12	381.99	0.1%	
	$C_{10}H_9O_{12}$	383.00	0.1%	
	$C_{10}H_{10}O_{12}$	384.01	0.2%	
	$C_{10}H_{11}O_{12}$	385.01	0.2%	
	$C_{10}H_{12}O_{12}$	386.02	0.4%	
	C ₁₀ H ₁₃ O ₁₂	387.03	0.1%	
	$C_{10}H_{14}O_{12}$	388.04	0.2%	
	C ₁₁ H ₁₄ O ₁₃	416.03	0.02%	
C ₁₁₋₁₉ dimeric products	$C_{14}H_{14}O_{12}$	436.04	0.04%	
-	$C_{18}H_{12}O_{12}$	482.02	0.02%	
	C ₂₀ H ₁₄ O ₈	444.06	0.01%	
	$C_{20}H_{16}O_8$	446.07	0.02%	
	$C_{20}H_{16}O_{9}$	462.07	0.03%	
	C ₂₀ H ₁₈ O ₉	464.08	0.01%	
	$C_{20}H_{14}O_{10}$	476.05	0.02%	
	$C_{20}H_{16}O_{10}$	478.06	0.03%	
	$C_{20}H_{18}O_{10}$	480.08	0.02%	
	C ₂₀ H ₁₄ O ₁₁	492.04	0.02%	
	C ₂₀ H ₁₆ O ₁₁	494.06	0.03%	
C ₂₀ dimeric products	C ₂₀ H ₁₈ O ₁₁	496.07	0.03%	
	$C_{20}H_{20}O_{11}$	498.09	0.02%	
	$C_{20}H_{14}O_{12}$	508.04	0.02%	
	$C_{20}H_{16}O_{12}$	510.05	0.01%	
	$C_{20}H_{18}O_{12}$	512.07	0.02%	
	$C_{20}H_{20}O_{12}$	514.08	0.03%	
	$C_{20}H_{22}O_{12}$	516.10	0.01%	
	$C_{20}H_{20}O_{13}$	530.08	0.01%	
	C20H18O14	544.06	0.02%	
	$C_{20}H_{20}O_{14}$	546.07	0.03%	

 $\label{eq:constraint} \textbf{Table S6.} Parts of the peak list for 1-methylnaphthalene (C_{11}H_{10}) oxidation products shown in Fig. 1f.$

Category	Formula	m/z (Th)	Fraction of total fitted signals
	C ₂ H ₄ O ₅	181 99	4 1%
	C4H4O5	193 99	2.7%
	C ₄ H ₄ O ₅	196.01	0.4%
	C ₄ H ₆ O ₅	205.99	0.8%
	C ₅ H ₄ O ₅	208.01	1.0%
C _{2.10} monomeric products	$C_{4}H_{4}O_{4}$	212.00	0.6%
C2-10 monomente products	$C_{4}H_{6}O_{6}$	2212.00	4.0%
	C5H4O6	224.00	3.0%
	C ₆ H ₆ O ₆	236.00	1.9%
	$C_{5}H_{6}O_{7}$	240.00	1.2%
	CeHeO7	252.00	2.8%
	$C_{11}H_{10}O_5$	284.04	0.4%
	$C_{11}H_{11}O_5$	285.05	0.05
	$C_{11}H_{12}O_5$	286.06	0.1%
	$C_{11}H_8O_6$	298.02	0.7%
	$C_{11}H_9O_6$	299.03	0.1%
	$C_{11}H_{10}O_6$	300.04	0.7%
	$C_{11}H_{11}O_6$	301.04	0.1%
	$C_{11}H_{12}O_6$	302.05	0.2%
	$C_{11}H_8O_7$	314.02	0.4%
	$C_{11}H_9O_7$	315.02	0.2%
	$C_{11}H_{10}O_7$	316.03	0.6%
	$C_{11}H_{11}O_7$	317.04	0.1%
	$C_{11}H_{12}O_7$	318.05	0.4%
	$C_{11}H_{14}O_7$	320.06	0.2%
	$C_{11}H_8O_8$	330.01	0.4%
	$C_{11}H_9O_8$	331.02	0.1%
	$C_{11}H_{10}O_{8}$	332.03	0.8%
	$C_{11}H_{11}O_8$	333.03	0.2%
	$C_{11}H_{12}O_8$	334.04	1.0%
	$C_{11}H_{13}O_8$	335.05	0.1%
	$C_{11}H_{14}O_8$	336.06	0.5%
	$C_{11}H_8O_9$	346.01	0.3%
	$C_{11}H_9O_9$	347.01	0.1%
	$C_{11}H_{10}O_{9}$	348.02	0.9%
	$C_{11}H_{11}O_9$	349.03	0.1%
C ₁₁ monomeric products	$C_{11}H_{12}O_9$	350.04	1.6%
	$C_{11}H_{13}O_9$	351.04	0.2%
	$C_{11}H_{14}O_9$	352.05	1.1%
	C11H16O9	354.07	0.2%
	$C_{11}H_8O_{10}$	362.00	0.4%
	C11H9O10	363.01	0.2%
	$C_{11}H_{10}O_{10}$	364.02	1.0%
	$C_{11}H_{11}O_{10}$	365.02	0.1%
	$C_{11}H_{12}O_{10}$	366.03	2.1%
	C11H13O10	367.04	0.2%
	$C_{11}H_{14}O_{10}$	368.05	1.9%
	$C_{11}H_{16}O_{10}$	370.06	0.5%
	$C_{11}H_{10}O_{11}$	380.01	0.8%
	$C_{11}H_{11}O_{11}$	381.02	0.1%
	$C_{11}H_{12}O_{11}$	382.03	1.8%
	$C_{11}H_{13}O_{11}$	383.03	0.2%
	$C_{11}H_{14}O_{11}$	384.04	1.8%
	$C_{11}H_{16}O_{11}$	386.06	0.7%
	$C_{11}H_{10}O_{12}$	396.01	0.4%
	$C_{11}H_{11}O_{12}$	397.01	0.2%
	$C_{11}H_{12}O_{12}$	398.02	1.3%
	$C_{11}H_{13}O_{12}$	399.03	0.2%
	$C_{11}H_{14}O_{12}$	400.04	1.3%
	$C_{11}H_{16}O_{12}$	402.05	0.6%
	$C_{11}H_{10}O_{13}$	412.00	0.2%

	$C_{11}H_{11}O_{13}$	413.01	0.1%	
	$C_{11}H_{12}O_{13}$	414.02	0.6%	
	C ₁₁ H ₁₃ O ₁₃	415.02	0.2%	
	C11H14O13	416.03	0.7%	
	C ₁₁ H ₁₆ O ₁₃	418.05	0.4%	
	$C_{11}H_{10}O_{14}$	428.00	0.1%	
	$C_{11}H_{12}O_{14}$	430.01	0.3%	
	$C_{11}H_{13}O_{14}$	431.02	0.1%	
	$C_{11}H_{14}O_{14}$	432.03	0.4%	
	$C_{11}H_{16}O_{14}$	434.04	0.2%	
C dimensio mas dusta	C13H18O4	300.11	0.04%	
C ₁₂₋₂₁ dimeric products	$C_{20}H_{10}O_5$	392.04	0.02%	
	C22H18O9	488.08	0.02%	
	$C_{22}H_{22}O_9$	492.11	0.02%	
	C ₂₂ H ₁₈ O ₁₀	504.08	0.02%	
	$C_{22}H_{20}O_{10}$	506.09	0.02%	
	$C_{22}H_{22}O_{10}$	508.11	0.02%	
	C ₂₂ H ₂₄ O ₁₀	510.13	0.02%	
	$C_{22}H_{18}O_{11}$	520.07	0.04%	
	$C_{22}H_{20}O_{11}$	522.09	0.03%	
	$C_{22}H_{22}O_{11}$	524.10	0.04%	
	C ₂₂ H ₂₄ O ₁₁	526.12	0.02%	
C ₂₂ dimeric products	$C_{22}H_{20}O_{12}$	538.08	0.04%	
	$C_{22}H_{22}O_{12}$	540.10	0.05%	
	$C_{22}H_{24}O_{12}$	542.12	0.04%	
	C ₂₂ H ₁₈ O ₁₃	552.06	0.03%	
	$C_{22}H_{20}O_{13}$	554.08	0.03%	
	$C_{22}H_{22}O_{13}$	556.09	0.04%	
	C ₂₂ H ₂₄ O ₁₃	558.11	0.04%	
	$C_{22}H_{18}O_{14}$	568.06	0.01%	
	$C_{22}H_{20}O_{14}$	570.07	0.06%	
	$C_{22}H_{22}O_{14}$	572.09	0.05%	
	C ₂₂ H ₂₄ O ₁₄	574.10	0.04%	

	benzene (%)	toluene (%)	m-xylene (%)	1,3,5-trimethylbenzene (%)	naphthalene (%)	1-methylnaphthalene (%)
$C_x H_{y+1} O_5$	0.1	0.1	0.05	0.1	0.4	0.05
$C_x H_{y+1} O_6$	0.2	0.2	0.7	/	0.3	0.1
$C_x H_{y+1} O_7$	0.4	0.5	0.9	0.13	1	0.1
$C_x H_{y+1} O_8$	0.2	0.1	0.9	0.3	1.1	0.2
$C_x H_{y+1} O_9$	0.9	1	1	0.4	0.3	0.1
$C_{2x}H_{2y}O_{10-14}$	0.6	0.3	1.2	0.7	0.1	0.2
$C_{2x}H_{2y+2}O_{10-14}$	0.7	0.5	2.0	1.1	0.1	0.2
$C_{2x}H_{2y+4}O_{10-14}$	0.4	0.4	2.0	0.8	0.1	0.2

Table S7. Fraction of the major C_x -series monomers, and C_{2x} -series dimers selected from Tables S1-S6.

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